Notice of Allowability	Application No.	Applicant(s)	
	09/502,729	COHEN ET AL.	
	Examiner	Art Unit	
	Wai-Sing Louie	2814	
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.			
1. This communication is responsive to <u>3/26/04</u> .			
2. The allowed claim(s) is/are <u>1-13,15 and 16.</u>			
3. The drawings filed on 11 February 2000 are accepted by the Examiner.			
<ul> <li>4. ☐ Acknowledgment is made of a claim for foreign priority ur</li> <li>a) ☐ All b) ☐ Some* c) ☐ None of the:</li> <li>1. ☐ Certified copies of the priority documents have</li> <li>2. ☐ Certified copies of the priority documents have</li> </ul>	been received.		
3.  Copies of the certified copies of the priority documents have been received in this national stage application from the			
International Bureau (PCT Rule 17.2(a)).			
* Certified copies not received:			
Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application.  THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.			
5. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.			
6. CORRECTED DRAWINGS ( as "replacement sheets") must be submitted.			
(a) ☐ including changes required by the Notice of Draftsperson's Patent Drawing Review ( PTO-948) attached			
1) hereto or 2) to Paper No./Mail Date			
(b) ☐ including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date			
Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d).			
7. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.			
Attachment(s)			
1. Notice of References Cited (PTO-892)	5. Notice of Informal P	atent Application (PTO-1	52)
2.  Notice of Draftperson's Patent Drawing Review (PTO-948)	6. Interview Summary	(PTO-413),	
3. ☑ Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date 2/19/02	Paper No./Mail Dat 08), 7. ☐ Examiner's Amendo	nent/Comment	
4.   Examiner's Comment Regarding Requirement for Deposit	8. Examiner's Stateme	ent of Reasons for Allowa	nce
of Biological Material	9.		

**DETAILED ACTION** 

**EXAMINER'S AMENDMENT** 

An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR

1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

The application has been amended as follows:

In the claims

Cancel claims 17-34.

Allowable Subject Matter

The following is an examiner's statement of reasons for allowance:

The claimed invention is a diffusion barrier layer for semiconductor devices, the diffusion barrier layer having an upper surface, a lower surface and a central portion, the diffusion barrier layer comprising:

• Silicon, carbon, nitrogen and hydrogen, with the nitrogen possessing a low dielectric constant being non-uniformly distributed throughout the diffusion barrier layer, wherein the nitrogen is more concentrated near the lower and upper surfaces and the central portion is substantially devoid of nitrogen, the diffusion barrier layer being between about 7 nm and about 120 nm in thickness.

Reference Li et al. (US Pub 2002/002919) do not disclose a diffusion barrier layer having nitrogen concentration near the upper and lower surfaces and the central portion is substantially devoid of nitrogen.

Reference Hao et al. (US 5,939,763) do not disclose a diffusion barrier layer comprises silicon, carbon, nitrogen and hydrogen. The silicon oxynitride layer has the nitrogen concentration higher near the upper and lower surfaces, but the central portion has a nitrogen concentration of 10<sup>18</sup> atoms per CC, which is not devoid of nitrogen.

Therefore, the above references do not disclose the claimed invention of present application and claims 1-13 and 15-16 are allowed.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Wai-Sing Louie whose telephone number is (571) 272-1709. The examiner can normally be reached on 7:30 AM to 4:00 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael Fahmy can be reached on (571) 272-1705. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Wsl April 9, 2004.

// LONG/PHAM PRIMAPH EXAMINER